MODIFIED PTO/SB/08a (09-08)

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Not for submission under 37 CFR 1.99)

	10001F1ED F10/36/068 (09-06)		
Application Number	10/528,376		
Filing Date	December 5, 2005		
First Named Inventor	Masamichi MORITA		
Art Unit	1794		
Examiner Name	Gerard T. Higgins		
Attorney Docket Number	Q86778		

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Examiner Initials*	Cite No	Patent Number	Kind Code ¹	Issue Date	Name of Patentee or Applicant of cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
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Examiner Initials*	Cite No	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	T⁵			
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EXAMINER SIGNATURE					
Examiner Signature	/Gerard Higgins/	Date Considered	02/11/2009		